

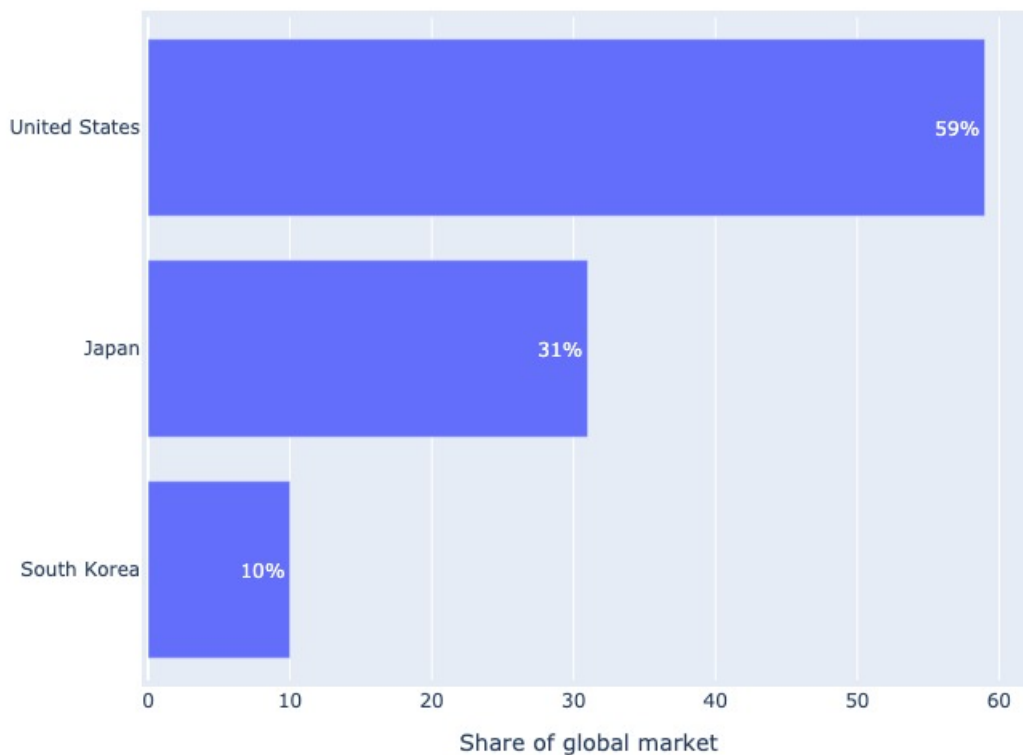
Supply Chain Explorer: Low-pressure CVD tools

This is an export from the Emerging Technology Observatory **Supply Chain Explorer** (<https://chipexplorer.eto.tech>). You can see the web version of this content at <https://chipexplorer.eto.tech/?filter-choose=input-resource&input-resource=N39>.

Low-pressure CVD tools

Low-pressure chemical vapor deposition tools are commonly used to deposit polysilicon, tungsten, titanium, and titanium nitride.

Supplier countries



Notable supplier companies

- Applied Materials - United States
- Lam Research - United States
- NAURA (negligible market share) - China (mainland)
- Tokyo Electron - Japan